

AMENDMENT TO THE SPECIFICATION

Please amend the Abstract of the present application as follows:

A wafer edge exposing apparatus comprising: includes a light source device for generating source light[[:]], an optical fiber cord for guiding the source light generated from the light source into a light focusing device[[:]], a lens, positioned in the light focusing device to receive the source light from the optical fiber cord, the light focusing device to focus the source light to the edge of a wafer[:], and a wavelength converter for converting a wavelength of the source light to a wavelength corresponding to the highest absorptivity of a photoacid generator of resist coated on the wafer.